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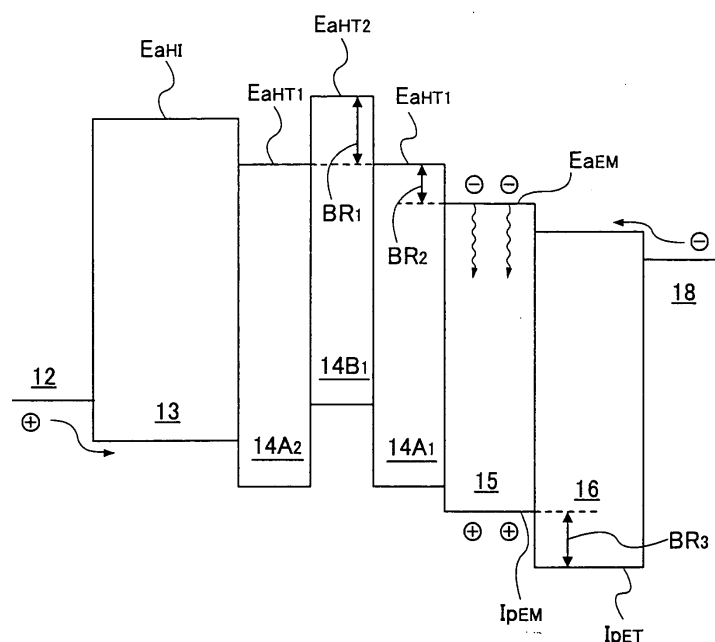
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(54) **ORGANIC ELECTROLUMINESCENCE ELEMENT AND ORGANIC ELECTROLUMINESCENCE DISPLAY**

(57) An organic electroluminescence device is disclosed. The device includes an anode, a cathode formed above the anode, a light-emitting layer containing an organic light-emitting material that is formed between the anode and the cathode, a hole-injecting layer on the anode that includes a hole-transporting material

and an acceptor, and an electron-transporting suppressing stack between the hole-injecting layer and the light-emitting layer. The electron-transporting suppressing stack consists of multiple carrier-transporting layers, and forms energy barriers relative to electrons flowing from the light-emitting layer to the hole-injecting layer.

FIG.2



Description

BACKGROUND OF THE INVENTION

1. Field of the Invention

[0001] The present invention generally relates to a technology for a photoelectronic device and a flat-panel display using a photoelectronic device, and particularly relates to an organic electroluminescence device and an organic electroluminescence display.

2. Description of the Related Art

[0002] In recent years, there has been a gradual shift in market needs from a conventional large and weighty CRT (a Braun tube) display to a thin and light-weight flat display. As for flat displays, LCD displays and plasma displays have been brought to commercial use as household television sets and PC monitors, etc.

[0003] Recently and continuing, attention is being given to an electroluminescence display (below called "EL display") and, more specifically, an organic EL display, as a next-generation flat display. Since a report on a stacking device with hole-transporting and electron-transporting organic thin-films (C.W Tang and S. A. Van Slyke, Applied Physics Letters vol. 51, 913 (1987)), an organic EL device for the organic EL display has attracted attention as a large-area light-emitting device for emitting light at a low voltage, not more than 10 volts, and is being studied actively.

[0004] A stacking organic EL device basically has a configuration of an anode, a hole-transporting layer, a light-emitting layer, an electron-transporting layer, and a cathode. Of these, the electron-transporting layer, as in the case of the double-layer device of Tang and Van Slyke as described above, is configured such that the light-emitting layer also serves the function of the electron-transporting layer. For the anode, electrode materials having a large work function such as gold (Au), tin oxide (SnO₂), and Indium Tin Oxide (ITO) are being used. Moreover, for the cathode, metals Li and Mg having a low work function with a small barrier for injecting the electrons into the electron-transporting layer, or their alloys Al-Li and Mg-Ag, etc., are being used.

[0005] Using various organic EL device structures and organic materials up to now has produced a luminance of about 1,000 cd/m² at a light-emitting voltage of 10 volts in the early stage of use. However, continuously driving the organic EL device over time results in a decreased light-emitting luminance and an increased drive voltage, eventually causing a short circuit.

[0006] It is considered that degradations of the organic EL device are due to crystallization over time of organic materials, the associated accumulation of space charges within the organic layer, and polarization due to applying the electric field in a certain direction, causing organic molecules to polarize the electrodes so as to

change the electric characteristic of the device, or degradations due to oxidization of the electrodes, etc. Moreover, when there is high power consumption, it is possible that the energy lost that changes to heat helps to degrade the organic material. Therefore, to increase the life of the device, desirably a highly-efficient device from which a high light-emitting luminance can be obtained at as low a current and voltage as possible should be implemented.

[0007] Thus, to achieve the high efficiency as described above, attempts are being made to increase the durability with a study in terms of materials and a method of driving the EL device. For example, as disclosed in JP06-036877A, a method is proposed that alternately repeats stacking of two types of organic layers for forming light-emitting layers such as to have energy bands of well-type potentials, so that electrons and holes not rebonding in one light-emitting layer rebond in the next light-emitting layer to emit light, thus increasing the light-emitting efficiency. However, with this configuration, a decreased voltage at each organic layer and generated Joule heat due to the high-resistance characteristics of the organic layers lead to a decrease in the light-emitting efficiency and the service life of the organic EL device.

[0008] In order to resolve this problem, as disclosed in JP04-297076A, a proposal is made for doping with acceptors within the hole-transporting layer to enhance conductivity.

[0009] In this case, while it is possible that the conductivity can be enhanced to increase the amount of hole current and the amount of electron current, as the carriers are not enclosed sufficiently, a problem arises such that the power consumption increases and the light-emitting efficiency and the service life decrease. Here, it is considered that as the electron affinity of the acceptors is generally greater than that of hole-injecting-transporting materials, decreasing the energy barrier at the interface of the hole-transporting layer and the light-emitting layer, which energy barrier encloses electrons within the light-emitting layer, makes efficient enclosing of electrons within the light-emitting layer not possible, causing the light-emitting efficiency to decrease.

[0010] As means for resolving this problem, as disclosed in JP2000-196140, a method is proposed for forming an electron-injecting suppressing layer that encloses electrons between the light-emitting layer and the hole-transporting layer, thus increasing the light-emitting efficiency. While there is less decrease in the light-emitting efficiency for a case of forming the electron-injecting suppressing layer than for a case of the hole-transporting layer directly bordering on the light-emitting layer, there is a problem that electrons that can pass through the electron-injecting-suppressing layer exist. While it is possible to increase the thickness of the electron-injecting suppressing layer so as to suppress such electrons as described above, at the same time, the flow of holes is suppressed, causing the luminance to de-

crease, so that there is yet to be a solution having satisfactory EL characteristics.

Patent Document 1

[0011] JP2000-196140A

SUMMARY OF THE INVENTION

[0012] It is a general object of the present invention to provide a technology for a photoelectronic device and a flat-panel display using a photoelectronic device that substantially obviates one or more problems caused by the limitations and disadvantages of the related art.

[0013] It is a more particular object of the present invention to provide an organic electroluminescence device and an organic electroluminescence display that have superior light-emitting efficiency and a long service life.

[0014] According to the invention, an organic electroluminescence device includes an anode, a cathode formed above the anode, a light-emitting layer containing an organic light-emitting material that is formed between the anode and the cathode, a hole-injecting layer on the anode that contains a hole-transporting material and an acceptor, and an electron-transporting suppressing stack between the hole-injecting layer and the light-emitting layer, wherein the electron-transporting suppressing stack consists of multiple carrier-transporting layers, and forms energy barriers relative to electrons flowing from the light-emitting layer to the hole-injecting layer.

[0015] The organic electroluminescence device as described above has superior light-emitting efficiency and a long service life.

[0016] Other objects and further features of the present invention will become apparent from the following detailed description when read in conjunction with the accompanying drawings.

BRIEF DESCRIPTION OF THE DRAWINGS

[0017]

FIG. 1 is a cross-sectional view of an organic EL device according to a first embodiment of the present invention;

FIG. 2 is an energy diagram of the organic EL device according to the first embodiment;

FIG. 3 is a cross-sectional view of the organic EL device according to a variation of the first embodiment of the present invention;

FIG. 4 is a graph for describing a method of deriving energy gaps;

FIG. 5 is a graph for describing a method of deriving ionizing potentials;

FIG. 6 is a table illustrating the characteristic values of the electron-transporting suppressing layer, the

hole-injecting layer, and the light-emitting layer used for the organic EL devices according to examples according to the present invention and comparative examples;

FIG. 7 is a table illustrating the layer configuration of specific elements of organic EL devices according to a first example, and first through third comparative examples; and

FIG. 8 is an exploded perspective view of the organic EL display according to a second embodiment of the present invention.

DETAILED DESCRIPTION OF THE PREFERRED EMBODIMENTS

[0018] In the following, embodiments of organic EL devices according to the present invention are described with reference to the accompanying drawings.

(A first embodiment)

[0019] FIG. 1 is a cross-sectional view of an organic EL device according to the first embodiment of the present invention. FIG. 2 is an energy diagram of the organic EL device according to the first embodiment as illustrated in FIG. 1. In FIG. 2, E_a denotes the electron affinity and I_p denotes the ionizing potential. Referring to FIGS. 1 and 2, an organic EL device 10 is configured with a substrate 11, an anode 12, a hole-injecting layer 13, an electron-transporting suppressing stack 14, a light-emitting layer 15, an electron-transporting layer 16 and a cathode 18 that are sequentially formed on the substrate 11.

[0020] The organic EL device 10 of the present invention has the hole-injecting layer 13 composed of a hole-transporting material that is doped with acceptors. The hole-injecting layer 13 is, for example 2-TNATA(4,4'-tris(2-naphthylphenylamino)triphenylamine), a hole-transporting material doped with inorganic materials such as halogen metal compounds, halogens, and platinum-group element metals, or organic materials having a cyano group or a nitro group as acceptors.

[0021] More specifically, as a hole-transporting material a known material may be used. Moreover, as preferable acceptors, the halogen metal compounds include FeCl_3 , InCl_3 , AsF_6 , etc., the halogens include Cl, Br, I, etc., and the platinum-group element metals include Au, Pt, W, Ir, etc. Furthermore, as preferable acceptors, the organic materials having a cyano group include TCNQ (7,7,8,8-tetracyanoquinonedi-methane), F4-TCNQ (2,3,5,6-tetrafluoro-7,7,8,8-tetracyanoquinonedi-methane), TCNE(tetracyanoethylene), etc., and the organic materials having a nitro group include TNF(trinitrofluorenone) and DNF(dinitrofluorenone), etc. Of these, TCNQ, F4-TCNQ, TCNE, TNF, and DNF are especially preferable.

[0022] The content of the acceptors in the hole-injecting layer 13 is set at 0.01 vol. % to 2.0 vol. a, preferably

at 0.05 vol. % to 1.0 vol. %, relative to hole-transporting materials (100 vol. %). Below 0.01 vol. %, the conductivity does not increase, while above 2.0 vol. %, the amount of current increases, causing the power consumption to increase. More specifically, when using F4-TCNQ as the acceptors, the content of the acceptors is preferably at 0.05 vol. % to 1.0 vol. %.

[0023] The hole-injecting layer 13 may be formed using such vacuum processes as vacuum deposition, CVD and sputtering, or such wet processes as spin coating and printing.

[0024] The organic EL device of the present invention is provided with the electron-transporting suppressing stack 14 between the hole-injecting layer 13 and the light-emitting layer 15. The electron-transporting suppressing stack 14 is formed sequentially stacked from the light-emitting layer 15 side toward the hole-injecting layer 13, by a first electron-transporting suppressing layer 14A₁, a second electron-transporting suppressing layer 14B₁, and a first electron-transporting suppressing layer 14A₂. The first electron-transporting suppressing layers 14A₁ and 14A₂, and the second electron-transporting suppressing layer 14B₁ that are composed from hole-transporting materials are arranged such that energy barriers are formed relative to the electrons from the light-emitting layer 15 side to the hole-injecting layer 13 side.

[0025] The first electron-transporting suppressing layers 14A₁ and 14A₂, and the second electron-transporting suppressing layer 14B₁ preferably have a relationship as represented in Equation (1) below:

$$E_{aHT1} > E_{aHT2} \quad (1)$$

Here, E_{aHT1} is the electron affinity of the first electron-transporting suppressing layers 14A₁ and 14A₂, while E_{aHT2} is the electron affinity of the second electron-transporting suppressing layer 14B₁. As the second electron-transporting suppressing layer 14B₁ for which the amount of the electron affinity is larger relative to the first electron-transporting suppressing layers 14A₁ and 14A₂ is formed between the two first electron-transporting suppressing layers 14A₁ and 14A₂, an energy barrier BR₁ is formed relative to the electrons at the interface from the first electron-transporting suppressing layers 14A₁ to the second electron-transporting suppressing layer 14B₁. Thus, the amount of electron current from the light-emitting layer 15 to the hole-injecting layer 13 is reduced.

[0026] Moreover, in addition, the light-emitting layer 15 and the first electron-transporting suppressing layer 14A₁ preferably have a relationship as represented in Equation (2) below:

$$E_{aHT1} < E_{aEM} \quad (2)$$

Here, E_{aEM} is the electron affinity of the light-emitting layer 15, while E_{aHT1} is the electron affinity of the first electron-transporting suppressing layer 14A₁. Also an energy barrier BR₂ is formed at the interface between the light-emitting layer 15 and the first electron-transporting suppressing layer 14A₁ so that the electrons are enclosed in the light-emitting layer 15. It is noted that the probability of electrons crossing the energy barrier BR₂ is high with the first electron-transporting suppressing layer 14A₁ being only one layer, and increasing the thickness of the first electron-transporting suppressing layer 14A₁ in order to reduce such probability as described above causes a large voltage drop that is not desirable in terms of durability. Moreover, such measure as described above may cause a decrease in the amount of hole-electron current. Thus, providing at the anode side of the light-emitting layer 15 the electron-transporting suppressing stack 14, which consists of multiple first and second electron-transporting suppressing layers and which has multiple energy barriers BR₁ and BR₂, effectively suppresses the amount of electron current proceeding from the light-emitting layer 15 toward the hole-injecting layer 13 and increases the space-electron density in the light-emitting layer 15 so as to increase the light-emitting efficiency.

[0027] Below, a specific configuration of the organic EL device according to the present embodiment is described.

[0028] For the substrate 11, what may be used are, for instance, such transparent base materials as glass, quartz, etc., such semiconductor substrates as Si, etc., such films as PET and PEN, etc., and such resin substrates as PVA. Or TFTs (Thin-Film Transistors) for controlling on and off of the organic EL device may be formed in a matrix shape on these substrates. The thickness of the substrate 11 that is selected accordingly depending on the materials of the substrate 11 is approximately 0.1 mm to 10 mm.

[0029] The anode 12 is formed on the substrate 11 by deposition or sputtering from conducting materials such as Al, and preferably such materials as Au, Cr, etc., which have a large work function are used from the hole-injection performance point of view. It is noted that when light is irradiated from the anode side, the anode 12 is formed from transparent materials such as ITO and IZO (Indium-Zinc-Oxide).

[0030] As hole-transporting materials for the hole-injecting layer 13, the first electron-transporting suppressing layer 14A, and the second electron-transporting suppressing layer 14B, materials having a high HOMO, or a small ionizing potential are used. Representative materials include copper phthalocyanin (CuPc), starburst amine m-MTDATA, 2-TNATA, TPD, α -NPD, etc.

[0031] It is noted that the ionizing potentials of the first electron-transporting suppressing layer 14A and the second electron-transporting suppressing layer 14B preferably are roughly equal from the point of view of increasing the amount of hole current. The energy bar-

riers may be formed low relative to the holes, suppressing the amount of electron current without inhibiting the flow of hole current.

[0032] Moreover, a further non-acceptor containing hole-injecting layer may be provided between the hole-injecting layer 13 and the anode 12. The further hole-injecting layer which is to be made to be a thin layer relative to the hole-injecting layer 13 is composed from a material having an ionizing potential that is almost equal to the size of the work function of the anode 12. Such measure as described above facilitates the flow of hole current.

[0033] For the light-emitting layer 15, such metal complex-based materials as Alq3(tris(8-hydroxyquinolinol) aluminum), Znq2, Balq2, and such pigment-based materials such as PZ10 and EM2 may be used. Moreover, host materials such as Alq3 that are doped with such pigments as Levulan and TPB may be used.

[0034] For the electron-transporting layer 16, 8-hydroxyquinoline metal chelates, metal thioxynoid compounds, oxadiazole metal chelates, triazine, 4,4'-bis(2,2-diphenyl vinyl)biphenyl, etc., may be used. Preferred 8-hydroxyquinoline metal chelates include Alq3, Balq(bis(8-hydroxyquinolate)-(4-phenylphenolate)aluminum), bis-PBD, etc. Moreover, preferred metal thioxynoid compounds include bis(8-quinolinethiolate)zinc, bis(8-quinolinethiolate)cadmium, tris(8-quinolinethiolate)gallium, tris(8-quinolinethiolate)indium, etc. Furthermore, preferred oxadiazole metal chelates include bis(2-(2-hydroxyphenyl)-5-phenyl-1,3,4-oxadiazolate) zinc, bis(2-(2-hydroxyphenyl)-5-phenyl-1,3,4-oxadiazolate)beryllium, bis(2-(2-hydroxyphenyl)-5-(1-naphthyl)-1,3,4-oxadiazolate)zinc, bis(2-(2-hydroxyphenyl)-5-(1-naphthyl)-1,3,4-oxadiazolate)beryllium, etc.

[0035] For the cathode 18, metals such as Li and their alloys Mg-Ag, Al-Li, etc., that have a small work function are used. Moreover, a cathode that introduces an electron-injecting layer of metal fluorides, etc., such as LiF/Al may be used.

[0036] As illustrated in FIG. 2, the electrons tend to flow from the light-emitting layer 15 towards the hole-injecting layer 13. However, the energy barrier BR_1 is formed at the interface between the first electron-transporting layer $14A_1$ and the second electron-suppressing layer $14B_1$ due to the difference in the electron affinities of these two layers $E_{aHT1} - E_{aHT2}$. Hereby the flow of electrons is prevented and the amount of electron current is suppressed, enclosing the electrons in the light-emitting layer 15. Moreover, the energy barrier BR_2 is formed at the interface between the light-emitting layer 15 and the first electron-transporting layer $14A_1$ due to the difference in the electron affinities of these two layers $E_{aEM} - E_{aHT1}$. Hereby furthermore the electrons are enclosed in the light-emitting layer 15. Thus the space-electron density of the light-emitting layer 15 is increased, increasing the probability of rebonding with the holes.

[0037] In the organic EL device of the present embodiment, the ionizing potentials of the electron-transporting layer 16 bordering the cathode 18 side of the light-emitting layer 15 and of the light-emitting layer 15 preferably have a relationship as represented in Equation (4) below:

$$I_{pEM} < I_{pET} \quad (4)$$

[0038] Here, in the Equation (4), I_{pEM} is the ionizing potential of the light-emitting layer 15, I_{pET} is the ionizing potential of the electron transporting layer 16 as described above, the ionizing potentials being represented as the difference (a positive value) between the valence electron level (the energy at the upper end of the valence-electron band) and the vacuum level. Providing an energy barrier BR_3 at the cathode 18 side of the light-emitting layer 15 encloses the holes in the light-emitting layer 15. Such measure as described above increases the space-hole density, increasing the probability of rebonding with electrons.

[0039] FIG. 3 is a cross-sectional view of the organic EL device according to a variation of the present embodiment. In the figure, those parts corresponding to the parts described previously are given the same reference letters so as to abbreviate the descriptions.

[0040] Referring to FIG. 3, an organic EL device 20 of the present variation is configured with a substrate 11, and an anode 12, a hole-injecting layer 13, an electron-transporting suppressing stack 24, a light-emitting layer 15, an electron-transporting layer 16, and a cathode 18 that are sequentially formed on the substrate 11. The electron-transporting suppressing stack 24 is composed from a first set of a first electron-transporting suppressing layer $24A_1$ and a second electron-transporting suppressing layer $24B_1$ to an N-th set of the first electron-transporting suppressing layer $24A_N$ and the second electron-transporting suppressing layer $24B_N$. Here, the number of sets to be stacked N is an integer no less than 2, and the N-th set may be formed with only the first electron-transporting suppressing layer $24A_N$.

[0041] For a larger number of sets to be stacked N, the first electron-transporting suppressing layer $24A$ and the second electron-transporting suppressing layer $24B$ are set to be thin. The total thickness of the electron-transporting suppressing stack 24 preferably is set at 150 nm to 500 nm. Setting the total thickness as described above 500 nm results in a large electric resistance, making it not possible to put through the current sufficiently, and applying a high voltage causes the service life of the organic EL device 20 to be reduced. Furthermore, setting the total thickness as described below 150 nm makes it not possible to sufficiently suppress the amount of electron current flowing from the light-emitting layer 15 side to the hole-injecting layer 13.

[0042] More specifically, the thickness of each of the

first electron-transporting suppressing layers 24A and the second electron-transporting suppressing layers 24B is set at 2 nm to 50 nm, and more preferably at 2 nm to 20 nm. Making the first electron-transporting suppressing layers 24A and the second electron-transporting suppressing layers 24B thin encloses the electrons in the light-emitting layer 15 and prevents blocking the flow of holes.

[0043] According to the present variation, providing the electron-transporting suppressing stack 24 with a large number of sets each consisting of a first electron-transporting-suppressing layer 24A and a second electron-transporting suppressing layer 24B and thus with a large number of energy barriers relative to the electrons suppresses more reliably the flow of electrons and prevents blocking the flow of holes.

[0044] It is noted that the electron-transporting suppressing stacks 14 and 15 in the organic EL devices 10 and 20 according to the first embodiment and the variation as described above, are composed of two types of electron-transporting suppressing layers, but may be composed of three or more types of electron-transporting suppressing layers. For example, using a third electron-transporting suppressing layer as well as the first and second electron-transporting suppressing layers, from the light-emitting layer 15 side to the hole-injecting layer 13, the layers are set in the order of the first electron-transporting suppressing layer / the second electron-transporting suppressing layer / the first electron-transporting suppressing layer / the second electron-transporting suppressing layer / the third electron-transporting suppressing layer / the first electron-transporting suppressing layer. The relationship among the electron affinities of the three types of the electron-transporting suppressing layers is set as represented in Equation (5) below:

$$E_{aHT1} > E_{aHT2} > E_{aHT3} \quad (5)$$

[0045] Here, in the Equation (5), E_{aHT1} is the electron affinity of the first electron-transporting suppressing layer, E_{aHT2} is the electron affinity of the second electron-transporting suppressing layer, and E_{aHT3} is the electron affinity of the third electron-transporting suppressing layer. Forming relative to the electrons an energy barrier at the interface of the second electron-transporting suppressing layer and the third electron-transporting suppressing as well as an energy barrier at the interface of the first electron-transporting suppressing layer and the second electron-transporting suppressing layer, thus forming within the electron-transporting suppressing stack energy barriers having different sizes, enhances the suppressibility of the flow of electrons.

[0046] Moreover, the first electron-transporting suppressing layer 14A or the second electron-transporting suppressing layer 14B bordering the cathode 18 side of

the hole-injecting layer 13 preferably has a relationship as represented in Equation (3) below:

$$E_{aHT} > E_{aHI} \quad (3)$$

[0047] Here, in Equation (3), E_{aHT} is the electron affinity of the first or the second carrier transporting layer bordering the cathode 18 side of the hole-injecting layer 13, and E_{aHI} is the electron affinity of the hole-injecting layer 13. Providing an energy barrier at a location prior to the electrons reaching the hole-injecting layer 13 when flowing from the light-emitting layer 15 side to the hole-injecting layer 13 suppresses the flow of electrons.

[0048] It is noted that in the present embodiment, the energy gap, the ionizing potential, and the electron affinity of each of the electron-transporting suppressing layers 14A, 14B, 24A, 24B, the light-emitting layer 15, and the electron-transporting layer 16, etc., were derived according to those measurement conditions and measurement methods as described below.

[0049] As for the energy gap Eg, the light-absorption spectrum was measured, setting the energy at the long-wavelength end of the light-absorption spectrum as the energy gap Eg. More specifically, under the same conditions as the conditions for forming each layer of the organic EL devices as described above, a particular one of the electron-transporting layers, etc., to be measured was individually formed at a thin film having a thickness of 50 nm. Using a spectrophotometric apparatus (manufactured by Hitachi, Co. Ltd., product name: Spectrophotometer-U-4100), ultra-violet to visible light was irradiated on a thick film in the atmosphere and the light-absorption spectrum (the wavelength dependency) was measured.

[0050] FIG. 4 is a characteristic diagram illustrating the light-absorption spectrum. Referring to FIG. 4, a point of intersection CP1 of a straight line extrapolated to the long-wavelength side using a straight-line approximation of a straight-line segment LN1 at the foot of the long-wavelength side of the light-absorption spectrum, and a straight line extrapolated to the short-wavelength side using a straight-line approximation of a straight-line segment BG1 at the background is converted to the energy gap Eg.

[0051] As for the ionizing potential Ip, the photoelectron-emission energy threshold measured using an ultra-violet photoelectron spectroscopy was set to be the ionizing potential Ip. More specifically, using a thick film formed in the same manner as the thick film used for measuring the energy gap Eg, with an ultra-violet photoelectron spectroscopic apparatus (manufactured by Riken Keiki Co., Ltd., product name: AC-1), the ultra-violet light was irradiated on a thin film in the atmosphere and the number of photoelectrons emitted was measured, so as to make a derivation from the relationship between the incident ultra-violet light energy and the

number of photoelectrons. The measurement conditions were such that the energy range of the incident ultra-violet light was at 3.8 to 6.2 eV and the ultra-violet light intensity was at 20 nW.

[0052] FIG. 5 is a characteristic diagram illustrating an example of the relationship between the square root of the number of photoelectrons and the incident ultra-violet light energy. Referring to FIG. 5, the energy at a point of intersection CP2 of a straight line extrapolated to the low-energy side using a straight-line approximation of a straight-line segment LN2 at the rise of the characteristic line, and a straight line extrapolated to the high-energy side using a straight-line approximation of a straight-line segment BG2 at the background is set as the ionizing potential I_p .

[0053] Moreover, the electron affinity E_a is derived as the difference between the ionizing potential I_p derived as described above and the energy gap E_g .

[0054] Using these methods, the energy gap, the ionizing potential, and the electric affinity are measured for the individual hole-transporting materials, so that combinations of the first and second electron-transporting suppressing layers and the light-emitting layer configuring the electron-transporting suppressing stack can be selected.

[0055] FIG. 6 is a table illustrating the measured values of the energy gap, the ionizing potential, and the electron affinity of the electron-transporting suppressing layer, the hole-injecting layer, and the light-emitting layer which configure the organic EL devices of examples according to the present invention and of comparative examples not in accordance with the present invention.

(A first example)

[0056] The organic EL device according to the present example is composed from an ITO anode, a hole-injecting layer, an electron-transporting suppressing stack consisting of three electron-transporting suppressing layers, a light-emitting layer, and a cathode that are formed on a transparent substrate.

[0057] A glass substrate with an ITO electrode is superpersonally cleansed with water, acetone, and isopropylalcohol, and the surface of the anode is irradiated with UV light in the atmosphere for 20 minutes so as to perform a UV ozone process. Then using a vacuum-deposition apparatus with a vacuum of 1×10^{-6} torr and a substrate temperature at 20 °C, 2-TNATA and F4-TCNQ as the hole injecting layers are simultaneously deposited at the respective deposition rate of 0.5 nm/s and 0.0005 nm/s and are each set to have the thickness of 120 nm. In other words, with 2-TNATA being 100 vol. %, the content of F4-TCNQ was set at 0.1 vol. %.

[0058] Then, the electron-transporting suppressing stack consisting of three layers is formed. α -NPD is formed at the deposition rate of 0.1 nm/s and the thickness of 10 nm, followed by 2-TNATA at the deposition rate of 0.1 nm/s and the thickness of 10 nm and then

α -NPD at the deposition rate of 0.1 nm/s and the thickness of 10 nm.

[0059] As the light-emitting layer, Alq3 is formed at the deposition rate of 0.1 nm/s and the thickness of 50 nm. Then on top of Alq3, Al-Li alloy (Li: 0.5 wt. %) is deposited at the deposition rate of 0.02 nm/s and the thickness of 50 nm, forming the organic EL device according to the first example. When applying to this device a voltage no less than 6 volts with ITO as the anode and Al-Li as the cathode, a green-color light emission was observed.

(A first comparative example)

[0060] The organic EL device according to the first comparative example is formed in the same manner as the first example except that 2-TNATA as the hole-injecting layer is deposited at the deposition rate of 0.5 nm/s and the thickness of 130 nm and α -NPD layer in lieu of the electron-transporting suppressing stack is formed at the deposition rate of 0.1 nm/s and the thickness of 20 nm.

(A second comparative example)

[0061] The organic EL device according to the second comparative example is formed in the same manner as the first example except that 2-TNATA as the hole-injecting layer is deposited at the deposition rate of 0.5 nm/s and the thickness of 10 nm, 2-TNATA and F4-TCNQ are simultaneously deposited on top of the hole-injecting layer as described above at the respective deposition rates of 0.5 nm/s and 0.0005 nm/s and the respective thicknesses of 120 nm, and α -NPD layer in lieu of the electron-transporting suppressing stack is formed at the deposition rate of 0.1 nm/s and the thickness of 20 nm.

(A third comparative example)

[0062] The organic EL device according to the third comparative example is formed in the same manner as the first example except that a α -NPD layer in lieu of the electron-transporting suppressing stack is formed at the deposition rate of 0.1 nm/s and the thickness of 20 nm.

[0063] FIG. 7 is a table illustrating the layer configuration of specific elements of the organic EL devices according to the first example, and first through third comparative examples. Referring to FIG. 7, it may be understood that the light-emitting efficiency of the organic EL device of the first example is high relative to the organic EL devices of the first to the third comparative examples. It may be understood that the organic EL device of the first example has not only the light-emitting luminance lower than the second and third comparative examples, but also the current density suppressed so that the light-emitting efficiency is enhanced. It may be deduced that the electron-transporting stack consisting of α -NPD and 2-NATA (with the difference in the electron affinities of

0.23 eV) reduces the amount of electron current to the electron-transporting suppressing layer from the light-emitting layer so that while the light-emitting luminance decreases, the probability of rebonding with the holes by the electrons enclosed in the light-emitting layer is increased, enhancing the light-emitting efficiency.

(A second embodiment)

[0064] FIG. 8 is an exploded perspective view of the organic EL display according to the second embodiment of the present invention. Referring to FIG. 8, an organic EL display 30 is configured with a glass substrate 31, and a cathode 32 formed on the glass substrate in a stripe shape, an anode 34 formed vertically opposing the cathode 31 in a stripe shape, and a stack 33, etc., formed between the cathode 32 and the anode 34. Moreover, the organic EL display 30 is configured with a drive circuit (not illustrated) for driving a voltage to be applied between the cathode and the anode, and an encapsulated container, etc., for preventing exposure to moisture.

[0065] In the organic EL display 30 a voltage is applied to the cathode 32 and the anode 34 of a desired region causing emitting light in the desired region. The feature of the organic EL display is that the organic EL device consisting of the anode 34, the stack 33 and the cathode 32 is composed from the organic EL device according to the first or second embodiment as described above. Thus, an organic EL display having a high light-emitting efficiency and a long service life is implemented.

[0066] While preferable embodiments of the present invention have been described in detail, the present invention is not limited to the embodiments so that variations and changes are possible within the scope of the present invention.

[0067] For example, in the present embodiment, the organic EL device may be formed on the substrate by sequentially stacking from the anode side or from the cathode side.

[0068] The present application is based on PCT application JP2003/004225, filed April 2, 2003, the entire contents of which are hereby incorporated by reference.

Claims

1. An organic electroluminescence device, comprising:

an anode;
a cathode formed above said anode;
a light-emitting layer containing an organic light-emitting material that is formed between said anode and the cathode;
a hole-injecting layer on the anode that includes a hole-transporting material and an ac-

ceptor;

an electron-transporting suppressing stack between the hole-injecting layer and the light-emitting layer;

characterized in that the electron-transporting suppressing stack consists of a plurality of carrier-transporting layers, and forms energy barriers relative to electrons flowing from the light-emitting layer to the hole-injecting layer.

2. The organic electroluminescence device as claimed in claim 1,

characterized in that said electron-transporting suppressing stack has arranged a first carrier-transporting layer bordering the anode side of the light-emitting layer and a second carrier-transporting layer bordering the anode side of said first carrier-transporting layer alternating repeatedly in said sequential order,

and **characterized in that** an electron affinity of the first carrier-transporting layer and an electron affinity of the second carrier-transporting layer have a relationship in an equation (1) represented as

$$E_{aHT1} > E_{aHT2} \quad (1)$$

where in the equation (1) E_{aHT1} is the electron affinity of the first carrier-transporting layer and E_{aHT2} is the electron affinity of the second carrier-transporting layer.

3. The organic electroluminescence device as claimed in claim 2,

characterized in that the electron affinity of the first carrier-transporting layer and an electron affinity of the light-emitting layer have a relationship in an equation (2) represented as

$$E_{aHT1} < E_{aEM} \quad (2)$$

where in the equation (2) E_{aHT1} is the electron affinity of the first carrier-transporting layer and E_{aEM} is the electron affinity of the light-emitting layer.

4. The organic electroluminescence device as claimed in claim 2,

characterized in that the electron affinity of the first carrier-transporting layer or the second carrier-transporting layer that faces the cathode side of said hole-injecting layer, and an electron affinity of the hole-injecting layer have a relationship in an equation (3) represented as

$$E_{aHT} > E_{aHI} \quad (3)$$

where in the equation (3) E_{aHT} is the electron affinity of the first or the second carrier-transporting layer that faces the cathode side of said hole-injecting layer and E_{aHI} is the electron affinity of the hole-injecting layer.

5. The organic electroluminescence device as claimed in claim 1,

further comprising an electron-transporting layer between said light-emitting layer and the cathode,

characterized in that an ionizing potential of said electron-transporting layer and an ionizing potential of said light-emitting layer have a relationship in an equation (4) represented as

$$I_{pEM} < I_{pET} \quad (4)$$

where in the equation (4) I_{pEM} is the ionizing potential of the light-emitting layer and I_{pET} is the ionizing potential of the electron-transporting layer.

6. The organic electroluminescence device as claimed in claim 2,

characterized in that the first carrier-transporting layer is as thick as or thicker than the second carrier-transporting layer.

7. The organic electroluminescence device as claimed in claim 2,

characterized in that a thickness of the first carrier-transporting layer and a thickness of the second carrier-transporting layer are in a range of 2 nm to 50 nm.

8. The organic electroluminescence device as claimed in claim 1,

characterized in that a content of the acceptor in the hole-injecting layer is in a range of 0.05 vol. % to 2 vol. %.

9. The organic electroluminescence device as claimed in claim 2,

characterized in that either one of said first carrier-transporting layer and said second carrier-transporting layer is made of the same material as the hole-transporting material of said hole-injecting layer.

10. The organic electroluminescence device as claimed in claim 2,

characterized in that said electron-transporting suppressing stack further includes a third

carrier-transporting layer,

and has arranged the first carrier-transporting layer, the second carrier-transporting layer, and the third carrier-transporting layer repeating systematically.

11. The organic electroluminescence device as claimed in claim 10,

characterized in that said electron-transporting suppressing stack has arranged the first carrier-transporting layer bordering the anode side of the light-emitting layer, the second carrier-transporting layer bordering the anode side of said first carrier-transporting layer, the third carrier-transporting layer bordering the anode side of said second carrier-transporting layer, and a further first carrier-transporting layer bordering the anode side of said second carrier-transporting layer,

and **characterized in that** an electron affinity of said first carrier-transporting layer and said further first carrier-transporting layer, an electron affinity of said second carrier-transporting layer, and an electron affinity of said third carrier-transporting layer have a relationship in an equation (5) represented as

$$E_{aHT1} > E_{aHT2} > E_{aHT3} \quad (5)$$

where in the equation (5) E_{aHT1} is the electron affinity of said first carrier-transporting layer, and said further first carrier-transporting layer, E_{aHT2} is the electron affinity of said second carrier-transporting layer, and E_{aHT3} is the electron affinity of said third carrier-transporting layer.

12. The organic electroluminescence device as claimed in claim 1,

further comprising a further hole-injecting layer between said anode and the hole-injecting layer, **characterized in that** said further hole-injecting layer is made of a hole-transporting material.

13. An organic electroluminescence display, comprising the electroluminescence device as claimed in claim 1.

FIG.1

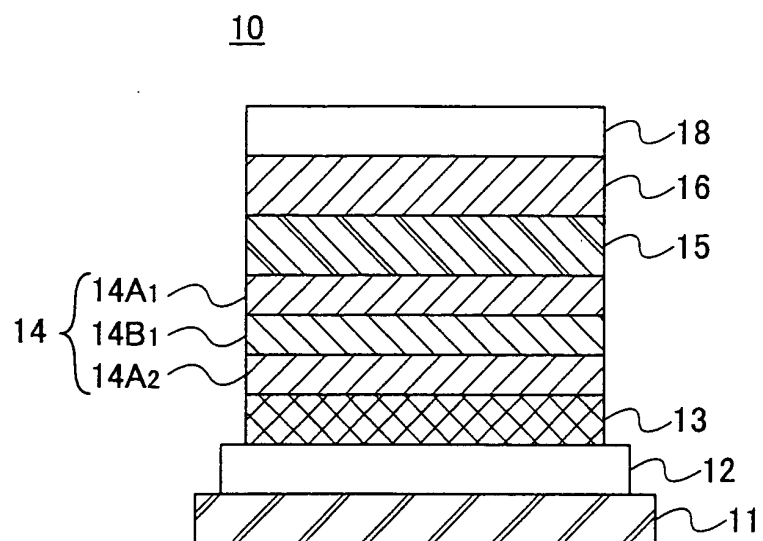


FIG.2

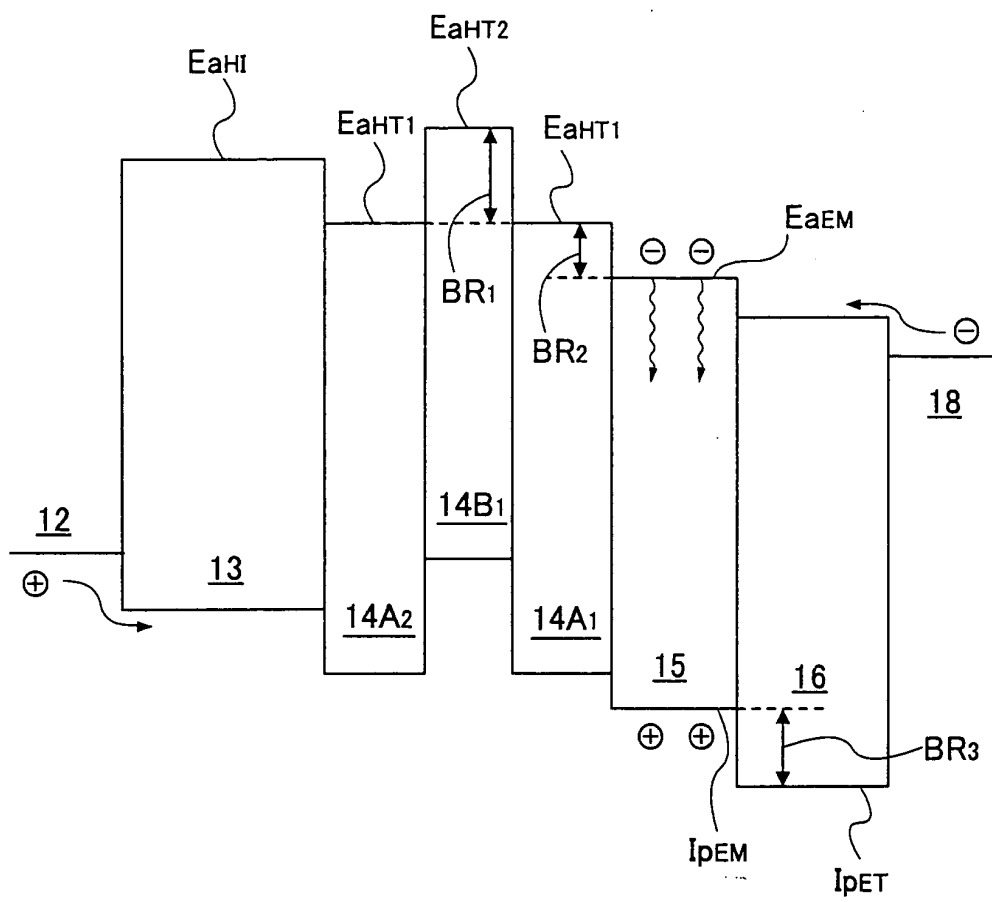


FIG.3

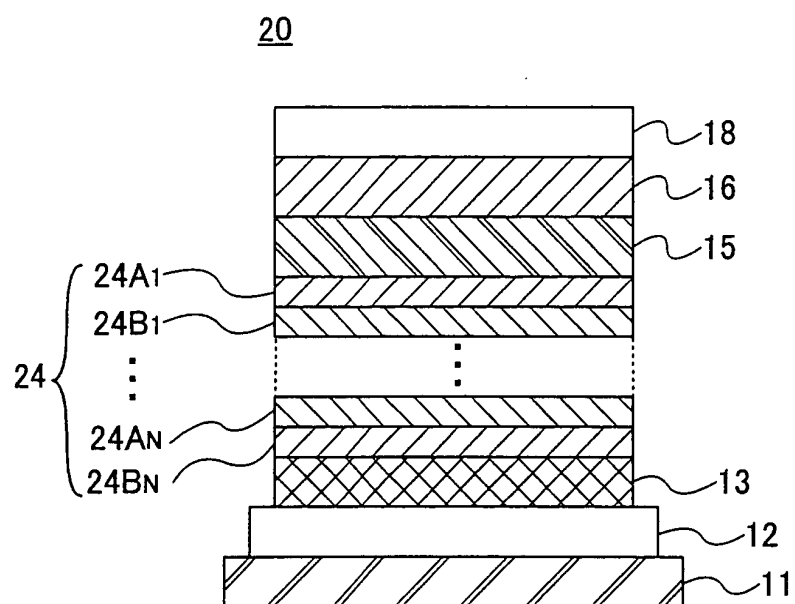


FIG.4

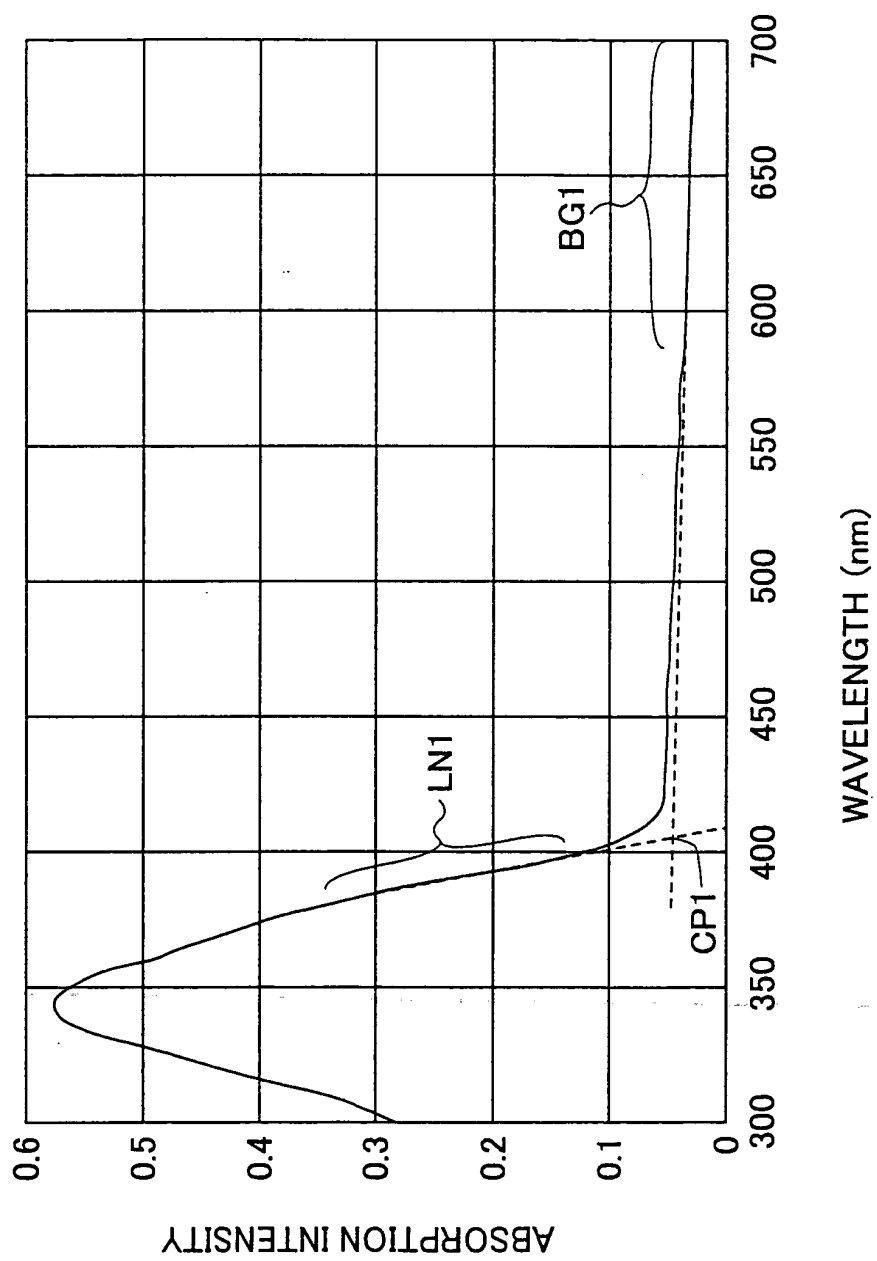


FIG.5

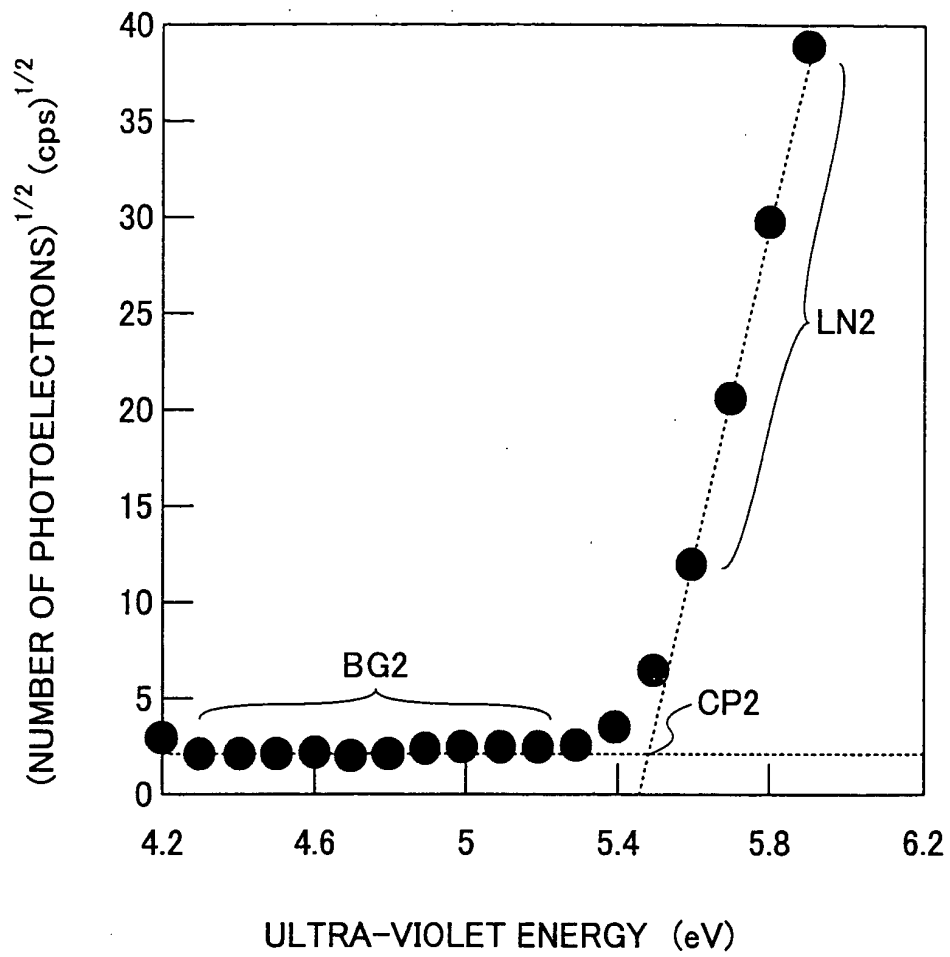


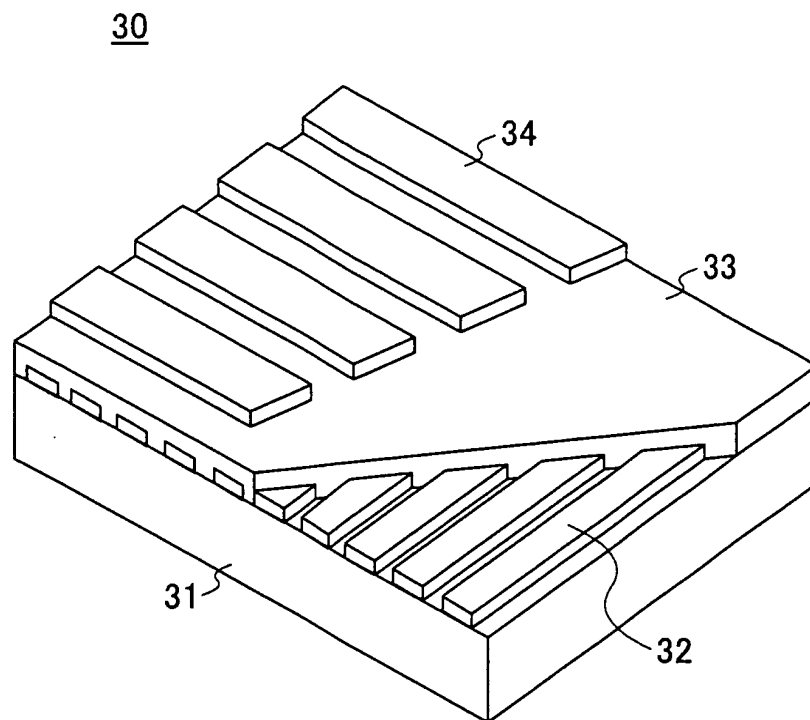
FIG.6

LAYER MATERIAL	ELECTRON AFFINITY Ea(eV)	ENERGY GAP Eg(eV)	IONIZING POTENTIAL Ip(eV)
2-TNATA LAYER	2.19	3.00	5.19
α -NPD LAYER	2.42	3.04	5.46
Alq3 LAYER	3.07	2.71	5.78
TYE-704 LAYER	2.97	2.76	5.73

FIG.7

	FIRST EXAMPLE	FIRST COMPARATIVE EXAMPLE	SECOND COMPARATIVE EXAMPLE	THIRD COMPARATIVE EXAMPLE
HOLE-TRANSPORTING-SUPPRESSING LAYER	α -NPD 2-TNATA α -NPD	α -NPD	α -NPD	α -NPD
HOLE-INJECTING LAYER	2-TNATA: F4-TCNQ (0.1 vol%)	2-TNATA	2-TNATA: F4-TCNQ (0.1 vol%) 2-TNATA	2-TNATA: F4-TCNQ (0.1 vol%)
CURRENT DENSITY(A/m ²)	352.8	105.6	476.7	412.1
LIGHT-EMITTING LUMINESCENCE(cd/m ²)	1203	207	1230	1224
LIGHT-EMITTING EFFICIENCY(cd/A)	3.41	1.96	2.58	2.97
LIGHT-EMITTING EFFICIENCY(lm/W)	1.07	0.62	0.81	0.93

FIG.8



INTERNATIONAL SEARCH REPORT

International application No.

PCT/JP03/04225

A. CLASSIFICATION OF SUBJECT MATTER Int.Cl ⁷ H05B33/22, H05B33/14		
According to International Patent Classification (IPC) or to both national classification and IPC		
B. FIELDS SEARCHED Minimum documentation searched (classification system followed by classification symbols) Int.Cl ⁷ H05B33/00-33/28		
Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched Jitsuyo Shinan Koho 1922-1996 Jitsuyo Shinan Toroku Koho 1996-2003 Kokai Jitsuyo Shinan Koho 1971-2003 Toroku Jitsuyo Shinan Koho 1994-2003		
Electronic data base consulted during the international search (name of data base and, where practicable, search terms used)		
C. DOCUMENTS CONSIDERED TO BE RELEVANT		
Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
Y A	JP 2002-507830 A (Cambridge Display Technology Ltd.), 12 March, 2002 (12.03.02), Claims; page 12, lines 1 to 11; page 16, lines 16 to 24; page 26, line 21 to page 27, line 7; page 32, 5th line from the bottom to page 34, last line; Figs. 21(a) to 21(b) & WO 99/48337 A	1-9, 12-13 10-11
Y A	JP 2000-196140 A (Sharp Corp.), 14 July, 2000 (14.07.00), Full text & EP 1017118 A	1-9, 12-13 10-11
<input checked="" type="checkbox"/> Further documents are listed in the continuation of Box C. <input type="checkbox"/> See patent family annex.		
* Special categories of cited documents: "A" document defining the general state of the art which is not considered to be of particular relevance "E" earlier document but published on or after the international filing date "L" document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified) "O" document referring to an oral disclosure, use, exhibition or other means "P" document published prior to the international filing date but later than the priority date claimed "T" later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention "X" document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone "Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art "&" document member of the same patent family		
Date of the actual completion of the international search 14 May, 2003 (14.05.03)		Date of mailing of the international search report 27 May, 2003 (27.05.03)
Name and mailing address of the ISA/ Japanese Patent Office		Authorized officer
Facsimile No.		Telephone No.

Form PCT/ISA/210 (second sheet) (July 1998)

INTERNATIONAL SEARCH REPORT

International application No.

PCT/JP03/04225

C (Continuation). DOCUMENTS CONSIDERED TO BE RELEVANT

Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
Y A	JP 2002-175887 A (Denso Corp.), 21 June, 2002 (21.06.02), Full text (Family: none)	1-5, 12-13 6-11

Form PCT/ISA/210 (continuation of second sheet) (July 1998)

专利名称(译)	有机电致发光元件和有机电致发光显示器		
公开(公告)号	EP1610594A1	公开(公告)日	2005-12-28
申请号	EP2003715737	申请日	2003-04-02
[标]申请(专利权)人(译)	富士通株式会社		
申请(专利权)人(译)	FUJITSU LIMITED		
当前申请(专利权)人(译)	富士胶片株式会社		
[标]发明人	ITAI YUICHIRO C O FUJITSU LIMITED		
发明人	ITAI, YUICHIRO, C/O FUJITSU LIMITED		
IPC分类号	H05B33/22 H01L51/00 H01L51/50 H05B33/12 H05B33/14		
CPC分类号	H01L51/5096 H01L51/0051 H01L51/0059 H01L51/006 H01L51/0077 H01L51/0081 H01L51/5048 H01L51/5088 Y10T428/24942		
其他公开文献	EP1610594A4		
外部链接	Espacenet		

摘要(译)

公开了一种有机电致发光器件。该装置包括阳极，形成在阳极上方的阴极，包含在阳极和阴极之间形成的有机发光材料的发光层，在阳极上包含空穴传输材料的空穴注入层和受主，以及空穴注入层和发光层之间的电子传输抑制叠层。电子传输抑制叠层由多个载流子传输层组成，并形成相对于从发光层流向空穴注入层的电子的能垒。

FIG.2

